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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : FUJIMOTO, Minoru
International Appl. No. : PCT/JP2004/000361
International Filing Date : 19, January 2004
For : METHOD FOR PROCESSING LIQUID-
HOLDABLE MATERIAL SUBSTANCE AND
PROCESSOR FOR PROCESSING LIQUID-
HOLDABLE MATERIAL SUBSTANCE

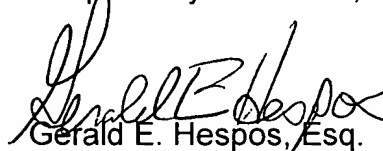
MS PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

This Information Disclosure Statement includes a copy of Form PTO-1449 that identifies five Japanese references. Copies of the references are attached as well. These references were identified as being relevant in the International Search Report, a copy of which is submitted concurrently with this Information Disclosure Statement. The Examiner is requested to consider these references during the examination and to make the references of record.

Respectfully submitted,



Gerald E. Hespos, Esq.
Atty. Reg. No. 30,066
Customer No. 001218
CASELLA & HESPOS LLP
274 Madison Avenue - Suite 1703
New York, NY 10016
Tel. (212) 725-2450
Fax (212) 725-2452

Date: July 13, 2006

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

Docket Number (Optional)

P1360US

Applicant

Minoru Fujimoto

Filing Date

Concurrently herewith

Group Art Unit

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U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

U.S. PATENT APPLICATION PUBLICATIONS

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FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
		49-109563	1974	Japan				✓
		57-058867	1982	Japan				✓
		62-205741	1987	Japan				✓
		1-124352	1989	Japan				✓
		9-275904	1997	Japan				✓

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.